What is claim is:

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- 1. A multichip module structure, at least comprising:
 - a first multichip module substrate, comprising:
 - an semiconductor substrate having a first surface and a second surface;
 - an insulating layer being on said first surface;
 - a multilayer interconnection structure being on said insulating layer and having a third surface having a plurality of first bonding pads and a fourth surface having a plurality of second bonding pads and contacting said insulating layer;
 - a plurality of conductive plugs penetrating said semiconductor substrate and said insulating layer and electrically connecting to said second bonding pads respectively;
 - a plurality of third bonding pads being on said second surface and connecting to said conductive plugs respectively; and
 - a plurality of chips being on said second surface and electrically connecting to said third bonding pads.
- 2. The multichip module structure according to claim 1, wherein said multilayer interconnection structure includes at least one integrated circuit device.
- 3. The multichip module structure according to claim 1, wherein said semiconductor substrate has a thickness between 10 to 500 micron meter.

- 4. The multichip module structure according to claim 1, wherein said chip is an active chip.
- 5. The multichip module structure according to claim 4, wherein said active chip is mounted on said second surface by flip-chip type.
- 5 6. The multichip module structure according to claim 1, wherein said chip is a passive chip.
 - 7. The multichip module structure according to claim 1, wherein said chips individually and electrically connect to said third bonding pads.
- 8. The multichip module structure according to claim 1, wherein said chips comprise a first active chip mounted on said first multichip module substrate by flip-chip type, and at least one chip electrically connecting and stacking on a backside of a first active chip.
 - 9. The multichip module structure according to claim 8, wherein said at least one chip comprises a second active chip mounted on said backside of said first active chip by flip-chip type.

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- 10. The multichip module structure according to claim 8, wherein said at least one chip comprises a passive chip.
- 11. The multichip module structure according to claim 1, further comprising a second multichip module substrate on said third surface, wherein said second multichip module substrate has a same structure as said first multichip module substrate.
- 12. The multichip module structure according to claim 1, wherein said multichip module structure is further electrically connected with a circuit board on said third surface.

13. A method for forming a multichip module structure, said method comprising:

providing a semiconductor substrate having a first surface and a second surface;

forming an insulating layer on said first surface;

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forming a multilayer interconnection structure on said insulating layer, said multilayer interconnection structure comprising a third surface having a plurality of first bonding pads and a fourth surface having a plurality of second bonding pads, and contacting said insulating layer;

forming a plurality of conductive holes penetrating said semiconductor substrate and said insulating layer and electrically connecting to said second bonding pads respectively;

forming a plurality of third bonding pads on said second surface,
wherein each said third bonding pad connects to said
conductive plugs respectively; and

mounting a plurality of chips on said second surface to electrically connect said third bonding pads.

- 20 14. The method according to claim 13, wherein said multilayer interconnection structure includes at least one integrated circuit device.
 - 15. The method according to claim 13, further comprising a step of polishing said semiconductor substrate on said second surface to

- reduce a thickness of said semiconductor substrate to 10 to 500 micron meter.
- 16. The method according to claim 13, wherein said chip is an active chip.
- 5 17. The method according to claim 16, wherein said active chip is mounted on said second surface by flip-chip type.
 - 18. The method according to claim 13, wherein said chip is a passive chip.
 - 19. The method according to claim 13, wherein said chips individually and electrically connect to said third bonding pads.
- 20. The multichip module structure according to claim 13, wherein said chips comprise a first active chip mounted on said first multichip module substrate by flip-chip type, and at least one chip electrically connecting and stacking on a backside of a first active chip.
- 21. The method according to claim 20, wherein said at least one chip comprises a second active chip mounted on said backside of said first active chip by flip-chip type.
 - 22. The method according to claim 20, wherein said at least one chip comprises a passive chip.
- 23. The method according to claim 13, further comprising mounting a circuit board on said third surface.
 - 24. The method according to claim 13, further comprising mounting a second multichip module substrate on said third surface, wherein said second multichip module substrate has a same structure as said first multichip module substrate.